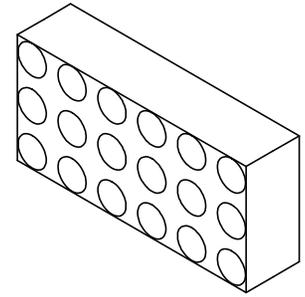


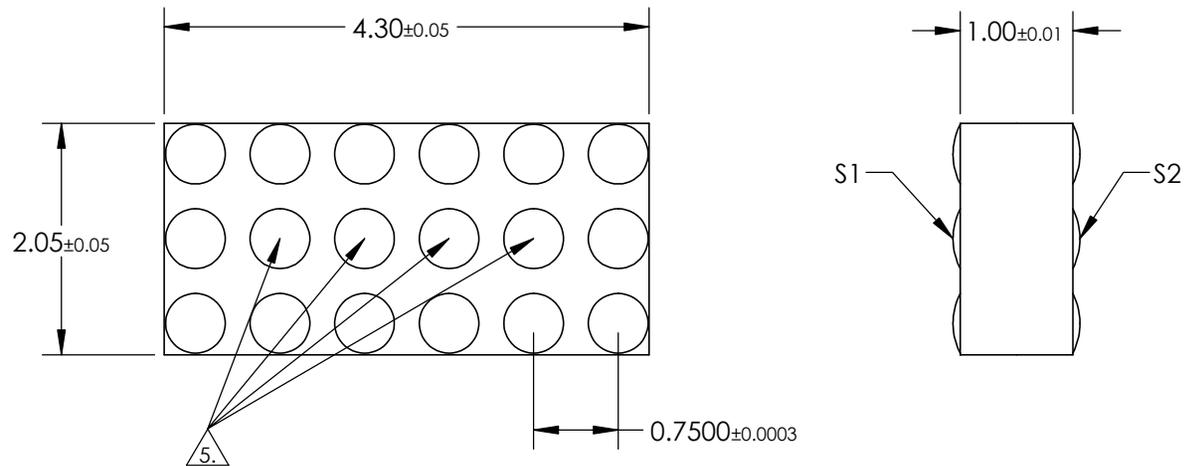
NOTES:

1. SUBSTRATE:
Fused Silica
2. COATING (APPLY ACROSS COATING APERTURE):
S1 & S2: R(AVG) $\leq 0.3\%$ @ 1250 - 1620
3. WORKING DISTANCE (mm):
0.6
4. MODE FIELD DIAMETER (mm):
Source: 0.0092
Target: 0.25



5. ACTIVE LENSES CENTERED ON SUBSTRATE

6. ROHS: COMPLIANT



SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

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**FOR INFORMATION ONLY:
DO NOT MANUFACTURE
PARTS TO THIS DRAWING**

THIRD ANGLE PROJECTION		TITLE	4.30 x 2.05mm, 0.575 ROC, 750µm Pitch, Fused Silica, 1 x 4 Linear Microlens Array	
ALL DIMS IN	mm	DWG NO	21174	SHEET 1 OF 1